	L#	Hits	S arch T xt	DBs
1	L2	16826	((inkjet\$4 or (fluid or ink or liquid) near3 (jet\$4 or eject\$)) with (printhead or printer or head or nozzle or orifice)).ti,ab.	US- PGPUB; USPAT
2	L4	69635	(photoresist or resist or photosensitiv\$8 or photopolymer\$8 or (photo or light or uv or ultraviolet or radiat\$8 or irradiat\$8) near3 (sensitiv\$8 or polymer or polymeris\$8 or polymeriz\$8 or crosslink\$8 or cross adj link\$8)).ti,ab.	US- PGPUB; USPAT
3	L5	311	2 and 4	US- PGPUB; USPAT
4	L6	924055	(metal\$8 or conduct\$8 or circuit\$4).ti,ab.	US- PGPUB; USPAT
5	L7	74	5 and 6	US- PGPUB; USPAT
6	L8	6295	sacrific\$8.ti,ab.	US- PGPUB; USPAT
7	L9	9	5 and 8	US- PGPUB; USPAT
8	L10	34264	((substrate or support or base) near5 (depart\$6 or detach\$6 or remov\$6 or strip\$6 or peel\$6)).ti,ab.	US- PGPUB; USPAT
9	L11	14	5 and 10	US- PGPUB; USPAT
10	L12	1057	430/320.ccls.	US- PGPUB; USPAT
11	L13	64	2 and 12	US- PGPUB; USPAT
12	L14	62	13 not (7 or 9 or 11)	US- PGPUB; USPAT
13	L20	793	347/47.ccls.	US- PGPUB; USPAT

	L#	Hits	Search T xt	DBs
14	L21	42	4 and 20	US- PGPUB; USPAT
15	L22	28	21 not (7 or 9 or 11 or 13)	US- PGPUB; USPAT
16	L23	366875	((substrate or support or base) near5 (depart\$6 or detach\$6 or remov\$6 or strip\$6 or peel\$6))	US- PGPUB; USPAT
17	L24	543706	(photoresist or resist or photosensitiv\$8 or photopolymer\$8 or (photo or light or uv or ultraviolet or radiat\$8 or irradiat\$8) near3 (sensitiv\$8 or polymer or polymeris\$8 or polymeris\$8 or crosslink\$8)	US- PGPUB; USPAT
18	L25	27235	23 same 24	US- PGPUB; USPAT
19	L26	3238483	(metal\$8 or conduct\$8 or circuit\$4)	US- PGPUB; USPAT
20	L27	9883	25 same 26	US- PGPUB; USPAT
21	L28	74	(2 or 20) and 27	US- PGPUB; USPAT
22	L29	1862	Huang-Chi\$.in.	US- PGPUB; USPAT
23	L30	468	chen-chia\$.in.	US- PGPUB; USPAT
24	L31	122	chuang-yu\$.in.	US- PGPUB; USPAT
25	L32	1	lion-jian\$.in.	US- PGPUB; USPAT
26	L33	117	liu-chien\$.in.	US- PGPUB; USPAT

	L#	Hits	Search Text	DBs
27	L34	1343	chen-chun\$.in.	US- PGPUB; USPAT
28	L35	3870	(29 or 30 or 31 or 32 or 33 or 34)	US- PGPUB; USPAT
29	L36	21	2 and 35	US- PGPUB; USPAT
30	L37	98743	(jet\$4 or eject\$)) with (printhead or printer or head or nozzle or orifice))	EPO; JPO; DERWE NT; IBM_TDB
31	L38	464704	(photoresist or resist or photosensitiv\$8 or photopolymer\$8 or (photo or light or uv or ultraviolet or radiat\$8 or irradiat\$8) near3 (sensitiv\$8 or polymer or polymeris\$8 or polymeriz\$8 or crosslink\$8 or cross adj link\$8))	EPO; JPO; DERWE NT; IBM_TDB
32	L39	5489205	(metal\$8 or conduct\$8 or circuit\$4)	EPO; JPO; DERWE NT; IBM_TDB
33	L40	176693	((substrate or support or base) near5 (depart\$6 or detach\$6 or remov\$6 or strip\$6 or peel\$6))	EPO; JPO; DERWE NT; IBM_TDB
34	L41	2653	37 and 38	EPO; JPO; DERWE NT; IBM_TDB
35	L42	682	41 and 39	EPO; JPO; DERWE NT; IBM_TDB

	L#	Hits	Search T xt	DBs
36	L43	67	40 and 42	EPO; JPO; DERWE NT; IBM_TDB
37	L44	20849	sacrific\$8	EPO; JPO; DERWE NT; IBM_TDB
38	L45	24	41 and 44	EPO; JPO; DERWE NT; IBM_TDB

	L#	Hits	Search T xt	DBs
1	L1	8647	((inkjet\$4 or (fluid or ink or liquid) near3 (jet\$4 or eject\$4)) with (printhead or printer or head or nozzle or orifice)).clm.	US- PGPUB
2	L2	31634	(photoresist or resist or photosensitiv\$8 or photopolymer\$8 or (photo or light or uv or ultraviolet or radiat\$8 or irradiat\$8) near3 (sensitiv\$8 or polymer or polymeris\$8 ro polymeriz\$8 or crosslink\$8 or cross adj link\$8)).clm.	US- PGPUB
3	L3	328348	(metal\$8 or conduct\$8 or circuit\$4).clm.	US- PGPUB
4	L4	23200	((substrate or support or base) near5 (depart\$6 or detach\$8 or remov\$6 or strip\$6 or peel\$8)).clm.	US- PGPUB
5	L5	35	1 and 2 and 3 and 4	US- PGPUB